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PATENT APPLICATION

In re the Application of

Attn: OIPE

Satoshi TAKEI et al.

Group Art Unit: 2812

Application No.:

10/584,133

Docket No.: 128515

Filed: October 23, 2006

For:

COMPOSITION FOR FORMING NITRIDE COATING FILM FOR HARD MASK

REQUEST FOR CORRECTION OF PALM RECORDS

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

Attached is a photocopy of the original filing receipt on which errors have been corrected in red. These errors are being brought to the attention of the Patent and Trademark Office so that it may correct its records.

Respectfully submitted,

James A. Oliff

Registration No. 27,075

Stephen P. Catlin

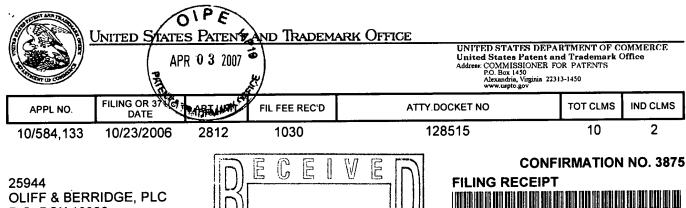
Registration No. 36,101

JAO:SPC/ejw

Date: April 3, 2007

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Applicant(s)

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Assignment For Published Patent Application

NISSAN CHEMICAL INDUSTRIES, LT., TOKYO, JAPAN CHEMICAL INDUSTRIES, LTD., TOKYO,

Power of Attorney: The patent practitioners associated with Customer Number 25944.

Domestic Priority data as claimed by applicant

This application is a 371 of PCT/JP04/19225 12/22/2004

Foreign Applications

JAPAN 2003-431792 12/26/2003

If Required, Foreign Filing License Granted: 03/22/2007

The country code and number of your priority application, to be used for filing abroad under the Paris Convention, is **US10/584,133**

Projected Publication Date: 06/28/2007

Non-Publication Request: No

. Early Publication Request: No

Title

Composition for forming nitride coating film for hard mask

Preliminary Class

438

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